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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/052,347	01/23/2002	Katsuhide Manabe	P 282475 F00-219-USdiv3-c	4113
75	7590 06/21/2004		EXAMINER	
Sean M McGinn			MULPURI, SAVITRI	
McGinn & Gibb PLLC 8321 Old Courthouse Road Suite 200 Vienna, VA 22182-3817			ART UNIT	PAPER NUMBER
			2812	
			DATE MAILED: 06/21/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	10/052,347	MANABE ET AL.				
Office Action Summary	Examiner	Art Unit				
·	Savitri Mulpuri	2812				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period w  - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	6(a). In no event, however, may a reply be timwithin the statutory minimum of thirty (30) days ill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).				
Status						
1)⊠ Responsive to communication(s) filed on 14 April 2004.						
,	action is non-final.					
3) Since this application is in condition for allowan						
Disposition of Claims						
4)  Claim(s) 19-52 and 119-127 is/are pending in the day of the above claim(s) is/are withdraw 5)  Claim(s) is/are allowed.  6)  Claim(s) 19-52,119-127 is/are rejected.  7)  Claim(s) is/are objected to.  8)  Claim(s) are subject to restriction and/or Application Papers	vn from consideration.					
9)☐ The specification is objected to by the Examiner.						
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.						
Applicant may not request that any objection to the care Replacement drawing sheet(s) including the correction 11). The oath or declaration is objected to by the Ex	on is required if the drawing(s) is ob	jected to. See 37 CFR 1.121(d).				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).  a) All b) Some color None of:  1. Certified copies of the priority documents have been received.  2. Certified copies of the priority documents have been received in Application No  3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).  * See the attached detailed Office action for a list of the certified copies not received.						
Attachment(s)  1) Notice of References Cited (PTO-892)  2) Notice of Draftsperson's Patent Drawing Review (PTO-948)  3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Do 5) Notice of Informal F 6) Other:					

## **DETAILED ACTION**

### Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 4/14/2004 has been entered.

# Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 19-52,119-127 are rejected under 35 U.S.C. 102(b) as being anticipated by Sayyah (Doctoral Dissertation presented in Feb.1986).

Sayyah discloses a method for producing a gallium nitride group compound semiconductor by MOCVD technique: setting a mixing ratio of silicon-containing gas to at least one other raw material gas (SiH<sub>4</sub>/ TMG+TMA) during vapor phase epitaxy at a range over which a conductivity of gallium nitride group compound semiconductor increases substantially proportionally with said mixing ration so as to obtain a desired conductivity as in claim 19 or concentration as in claim 20 of the gallium nitride group compound semiconductor, forming gallium nitride group nitride group compound

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semiconductor by feeding silicon containing gas and other raw material gas at mixing ratio, wherein the gallium nitride group compound semiconductor comprises Al<sub>x</sub>Ga<sub>1-x</sub>N or GaN with concentration of 1 X 10<sup>17</sup> / cm <sup>3</sup> to 1 X 10<sup>19</sup> / cm <sup>3</sup>. Page 125, first paragraph and table 14; fig.32 and related description). Sayyah clearly shows silicon concentration increases with increasing ratio of silane to mixture of TMG and TMA (see the plot fig. 32) and increase in silicon concentration increases the conductivity because conductivity is mobility of carriers times concentration. With respect to claims 28-30,34-36. Sayyah discloses electron concentration not less than 1 X 10<sup>16</sup> / cm <sup>3 in</sup> the range of 1 X 10<sup>17</sup> / cm <sup>3</sup>-1 X 10<sup>19</sup> / cm <sup>3</sup> depending on mole fraction as similar to instant claims(see page 37). With respect to claims 25-27,31-36, it is inherent in the invention of sayyah, the conductivity is similar because concentration of silicon in GaN based layer and growth technique to grow GaN based layer are similar in both instant invention and in the invention of Sayyah, wherein conductivity is carrier mobility times the concentration of silicon.

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 37-52 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sayyah in combination with Admitted prior art.

With respect to claims 37-52, though Sayyah teaches growing GaN based layer at temerarure as low as 500 C, but does not specifically mention growing GaN based layer on a gallium nitride based buffer layer, wherein buffer layer is grown at a temperature lower than GaN layer growth temperature. Admitted prior art teaches GaN layer grows directly on sapphire substrate or buffer layer of aluminum nitride. However such low temperature buffer layer growth is obvious because low temperature growth buffer layer inhibits the creation of defects or dislocations in the GaN layer to be grown on buffer layer.

#### Conclusion

Applicant's arguments with respect to claims 19-52, 119-127 have been considered but are most in view of the new ground(s) of rejection, where in new Sayyah reference (doctoral dissertation was applied).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Savitri Mulpuri whose telephone number is 571-272-1677. The examiner can normally be reached on Mon-Fri from 8 a.m. to 4.30 p.m.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Niebling, can be reached on 571-272-1679. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for

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published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only.

For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Savitri Mulpuri / Primary Examiner Art Unit 2812